



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

<u>In re application of:</u> Jochen C. Beintner	<u>Filed:</u> 12/08/2003
	<u>Examiner:</u> W. L. Lindsay, Jr.
<u>Serial No.</u> 10/730,582	<u>Group Art Unit:</u>
<u>Title:</u> Oxide/Nitride Stacked FinFET Spacer Process	<u>Docket #:</u> YOR920030417US1

AMENDMENT

Commissioner of Patents & Trademarks
Alexandria, VA 22313

Sir:

Responsive to the letter of 01/27/2005, please amend the above identified application as follows: